

10/733, 729

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	256	material and cavity and portion and atoms and implant\$ and etch\$ and surface and SOI	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/03 13:25
L2	39	1 and selectively and hydrogen and helium	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/03 13:27
L3	1	1 and selectively and hydrogen and helium and sub-surface	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/03 13:28